

Title (en)

STRUCTURE AND METHOD OF FORMING ELECTRICALLY BLOWN METAL FUSES FOR INTEGRATED CIRCUITS

Title (de)

STRUKTUR UND VERFAHREN ZUR FORMUNG ELEKTRISCH GEBLASENER METALLSICHERUNGEN FÜR INTEGRIERTE SCHALTKEIRE

Title (fr)

STRUCTURE ET PROCÉDÉ DE FORMATION DE FUSIBLES MÉTALLIQUES GRILLÉS ÉLECTRIQUEMENT POUR DES CIRCUITS INTÉGRÉS

Publication

EP 2433303 A1 20120328 (EN)

Application

EP 09845033 A 20090522

Priority

US 2009044952 W 20090522

Abstract (en)

[origin: WO2010134922A1] A fuse structure for an integrated circuit device includes an elongated metal interconnect layer (106) defined within an insulating layer; a metal cap layer (108) formed on only a portion of a top surface of the metal interconnect layer; and a dielectric cap layer (112) formed on both the metal cap layer (108) and the remaining portions of the metal interconnect layer not having the metal cap layer (108) formed thereon; wherein the remaining portions of the metal interconnect layer not having the metal cap layer (108) formed thereon are susceptible to an electromigration failure mechanism so as to facilitate programming of the fuse structure by application of electric current through the elongated metal interconnect layer (106).

IPC 8 full level

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CPC (source: EP)

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